## NOTES:

1. SUBSTRATE MATERIAL: N-BK7

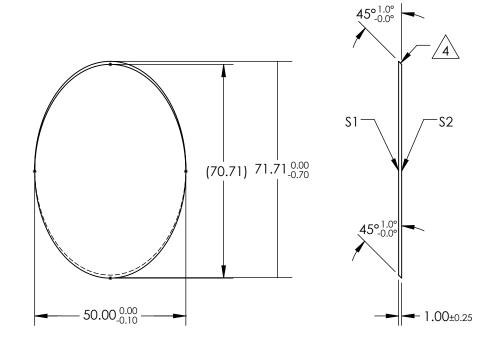
- 2. P1 PARALLEL TO P2 <1 ARCMIN
- 3. COATING (APPLY ACROSS CLEAR APERTURE)

S1: R(avg)= 50% ± 10% @ 700 - 1100nm R(abs)= 50% ± 5% @ 550nm T(avg)= 50% ± 10% @ 700 - 1100nm T(abs)= 50% ± 5% @ 550nm

S2: R(avg) ≤1.0% @ 700 - 1100nm R(avg) ≤2.0% @ 700 - 1100nm



5. ROHS COMPLIANT



## FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

REV. A	\$1	\$2			
SHAPE	PLANO	PLANO			
SURFACE QUALITY	60-40	60-40			
SURFACE FLATNESS	2λ per inch	2λ per inch			
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED			

				Edmund Optics	5
	THIRD ANGLE _ PROJECTION	$\phi \Box$	TITLE	50 x 70.71 x 1mm, NIR, ELLIPTICAL PLA BEAMSPLITTER	ATE
D	ALL DIMS IN	mm	DWG NO	48918	SHEET 1 OF 1